

<b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>	Docket number (Optional) <b>15689.73</b>	Application Number <b>09/889,000</b>
	Applicant(s) <b>Shinji Uebayashi et al.</b>	
	Filing Date <b>June 22, 2001</b>	Group Art Unit <b>2616</b>

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS							
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FOREIGN PATENT DOCUMENTS								
	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
	1	JP 07-212817	08/11/1995	Japan	H04Q7	22	X	

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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<b>*Examiner Initial</b>	<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>	
	<b>2</b>	<b>Official Notice of Rejection; Case No.: DCMH120076; Patent Application No.: 2000-190173</b>
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